



January 13, 2004

To: Commissioner for Patents
P.O.Box 1450
Alexandria, VA 22313-1450

Fr: George O. Saile, Reg. No. 19,572
28 Davis Avenue
Poughkeepsie, N.Y. 12603

Subject: | Serial No. 10/697,745 10/30/03 |

Wuping Liu et al.

SELF-PATTERNING OF PHOTO-ACTIVE
DIELECTRIC MATERIALS FOR INTER-
CONNECT ISOLATION

INFORMATION DISCLOSURE STATEMENT
Enclosed is Form PTO-1449, Information Disclosure Citation
In An Application.

The following Patents and/or Publications are submitted to
comply with the duty of disclosure under CFR 1.97-1.99 and
37 CFR 1.56.

CERTIFICATE OF MAILING

I hereby certify that this correspondence is being
deposited with the United States Postal Service as first class
mail in an envelope addressed to: Commissioner for Patents,
P.O. Box 1450, Alexandria, VA 22313-1450, on January 27, 2004.

Stephen B. Ackerman, Reg.# 37761

Signature/Date

A handwritten signature that appears to be "Stephen B. Ackerman" written over the date "1/27/04".

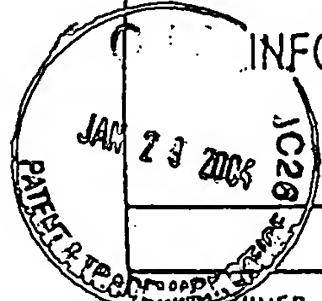
The following three U.S. Patents describe the use of photo-active dielectrics in printed circuit board manufacture:

- 1) U.S. Patent 6,506,979 to Shelnut et al., "Sequential Build Circuit Board."
- 2) U.S. Patent 5,334,488 to Shipley, Jr., "Method for Manufacture of Multilayer Circuit Board."
- 3) U.S. Patent 6,521,328 to Lauffer et al., "Copper Etching Compositions and Products Derived Therefrom."

U.S. Patent 6,349,456 to Dunn et al., "Method of Manufacturing Photodefined Integral Capacitor with Self-Aligned Dielectric and Electrodes," teaches forming a resistor using a photo-active dielectric (PAD).

Sincerely,

Stephen B. Ackerman,
Reg. No. 37761



Form PTO-1449

INFORMATION DISCLOSURE CITATION IN AN APPLICATION

(Use several sheets if necessary)

Doctor Number (Optional)

CS-03-025

Assignment Number

10/697,745

Appoint

Wuping Liu et al.

Filing Date

10/30/03

Group Art Unit

U. S. PATENT DOCUMENTS

FOREIGN PATENT DOCUMENTS

OTHER DOCUMENTS (including Author, Title, Date, Portion or Pages, Etc.)

EXAMINER

DATE CONSIDERED

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.